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Alignment procedure for radiation pattern measurements of antenna-coupled infrared detectors

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Abstract. An antenna-coupled detector's directional properties can be verified by measuring its angular radiation pattern. At infrared frequencies, this pattern can be measured by rotating the device while illuminating it with a laser beam. An accurate radiation pattern can be measured only if the device is coaligned with the axis of rotation and the focus of the laser beam. In the alignment procedure presented, the device is rotated to various angles and the distance along the orthogonal axis from the current device position to the laser beam is measured by maximizing its response. Calculations based on these distances provide the new location of the device, which will coalign it with the axis of rotation and the focus of the laser beam. The successful alignment enables accurate radiation pattern measurements. © 2010 Society of Photo-Optical Instrumentation Engineers. [DOI: 10.1117/1.3365959]

Subject terms: radiation pattern; alignment procedure; antenna-coupled detector; infrared antenna.

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1 Introduction

The concept of an antenna-coupled detector has been adapted from radio frequencies (rf) to much higher frequencies. It was first demonstrated at infrared (IR) frequencies,^{1,2} but it is also possible to use an antenna-coupled detector at the near-IR³ and even the visible part of the spectrum.⁴ The antenna can modify the detector's wavelength,⁵ directional,⁶ and polarization⁷ dependence. An angular map of its response, which is referred to as the radiation pattern, is used to validate the directional properties of the antenna design.^{8,9} The large dimensions of the antenna and measurement setup at rf frequencies make the alignment straightforward and positioning errors are generally small.¹⁰ At IR frequencies, the alignment must be more precise, since the dimensions involved are smaller.

This paper outlines a procedure that can be used to align an antenna-coupled detector to measure its receiving radiation pattern. The device is mounted on a goniometer and is rotated while being illuminated by a stationary laser beam. The goniometer is computer controlled and enables the device to rotate and move relative to the incident beam. To measure an accurate radiation pattern, the device must be coaligned with the axis of rotation of the goniometer and the focus of the laser beam. This ensures that the rotating device is illuminated with the maximum irradiance at all angles of incidence.

Descriptions of alignment procedures for optical systems typically follow two approaches. In both cases, a quantity is monitored from which information about the

optical system is gained. For instance, when aligning a laser diode to a fiber, the monitored quantity can be fiber optic coupling efficiency.¹¹ The light diffracted past the sharp edge of the perimeter of a fiber¹² can be monitored when aligning fiber segments to join them by splicing. For lenses or mirrors, the monitored quantity can be the ray aberration¹³ or wavefront errors.¹⁴

The first alignment approach adjusts the optical system iteratively, while minimizing the difference between the monitored quantity and its desired value. The second approach develops a theoretical description of the optical system based on the measured quantity. This theoretical description indicates how the optical system is misaligned. The system is then adjusted to remove the errors in alignment.

The alignment procedure described here follows the second approach, in which the response and position of the device are monitored. The goniometer is used to rotate the device and then move it along orthogonal axes until it intercepts the beam, which will maximize its response. Based on these adjustments, we can determine how to move the device to coalign it with the axis of rotation. The goniometer is then moved so that the device and the axis of rotation are coaligned with the focus of the laser beam. Since the presented alignment procedure relies only on maximizing the device response, it can be applied to measure arbitrarily shaped radiation patterns.

2 Experimental Setup

The alignment procedure was developed to measure radiation patterns of IR antenna-coupled bolometers that were fabricated directly on the flat surface of a hemispherical

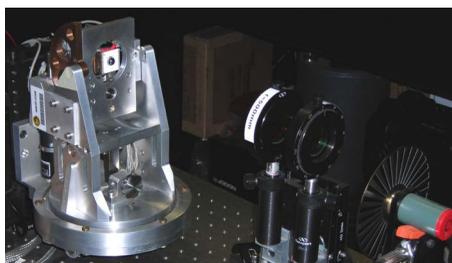


Fig. 1 Measurement setup showing goniometer and the focusing lenses.

silicon lens.⁹ A CO₂ laser operating at 10.6 μm is focused onto the device at *F*/8. The device is mounted on a five-axis goniometer, which is shown in Fig. 1. Its position can be manipulated in *x*, *y*, and *z* as well as rotated and tilted about the center of the goniometer.

The goniometer can be moved externally, both perpendicular or parallel to the laser beam, thus enabling the device to be positioned with eight degrees of freedom. Its movements are computer controlled, enabling precise positioning and monitoring of the device location.

3 Alignment Procedure

A graphical representation of the top view of the goniometer is shown in Fig. 2. The rotational axis is represented as a cross at (0,0). It forms the origin of the internal coordinate system along which the device can be moved and rotated about. The laser beam, propagating in the *z* direction, and its waist are shown. For the purpose of illustration, a large-diameter beam with exaggerated divergence is shown. Its focus is located at (*z_f*, *x_f*). The external goniometer movement will simultaneously reposition the axis of rotation and the device with respect to the focus of the laser beam.

The device, indicated by the black square in Fig. 2, is mounted on the goniometer. The gray line shows the surface of the substrate on which the device is fabricated. It is

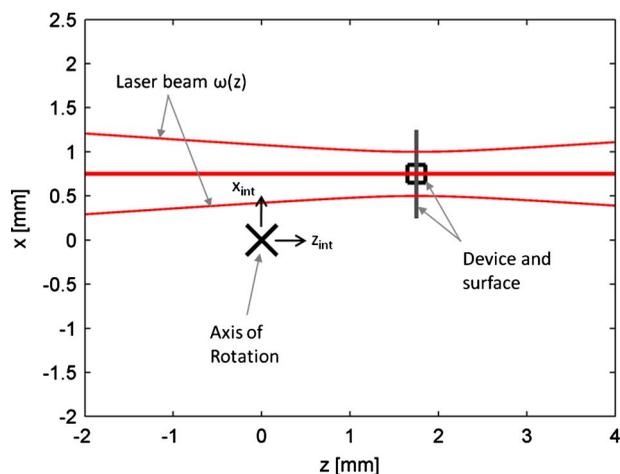


Fig. 2 Top view of the goniometer showing the axis of rotation, the device, the substrate surface, and the laser beam.

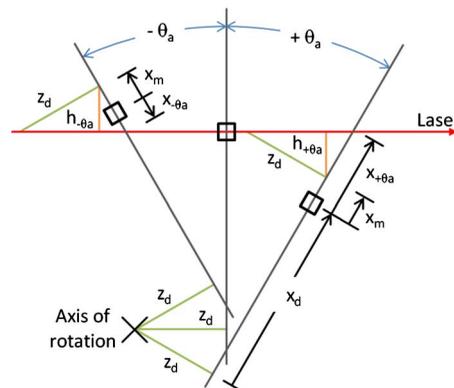


Fig. 3 Geometrical representation of device location with respect to the rotational axis for $\theta = \pm \theta_a$ and $\theta = 0$ deg for alignment of the internal *z* position. The device is offset in both the *z* and *x* directions.

parallel to the internal *x* axis and indicates the rotation of the device. In Fig. 2 the rotation is set to $\theta = 0$ deg, and the position of the device is adjusted along the internal axes until its response is maximized. This occurs when the location of the device coincides with the focus of the laser beam, i.e., (*z_d*, *x_d*) = (*z_f*, *x_f*).

3.1 Alignment Process for Internal *z* Axis

At this point, the device is aligned only at $\theta = 0$ deg. A radiation pattern measurement would not yield an accurate pattern, since rotating the device moves it away from the laser beam. A maximum amount of irradiance is illuminating the device only at broadside. The alignment process begins by removing the offset in the *z* direction between the device and the axis of rotation.

Figure 3 shows the device, indicated as a square, located at (*z_d*, *x_d*) for three different rotation locations: $\theta = \pm \theta_a$, and $\theta = 0$ deg. Since $h_{+\theta_a} = h_{-\theta_a}$, it can be shown that

$$x_m = \frac{x_{+\theta_a} + x_{-\theta_a}}{2} \tag{1}$$

If the device is positioned at (*z_d*, *x_d* + *x_m*) and rotated to either $\theta = -\theta_a$ or $\theta = +\theta_a$, its response will be maximized when it is displaced along the internal *z* axis by $-z_d$ to its new location at (0, *x_d* + *x_m*).

In practice, the rotation is set to $\theta = 0$ deg and the device is located at the focus of the laser beam. The goniometer is rotated to $\theta = +\theta_a$ and the device is adjusted along the internal *x* direction until its response is maximized. This occurs when the device intercepts the center of the laser beam and a maximum irradiance is falling on it. The direction and distance the device was moved is *x_{+θ_a}*. After restoring the device to its original position, the goniometer is rotated to $\theta = -\theta_a$ and *x_{-θ_a}* is determined. These two steps are illustrated in Fig. 4 for the case where $\theta_a = 40$ deg. The device location where its response is maximized is indicated by an asterisk. Both *x_{+θ_a}* and *x_{-θ_a}* are shown.

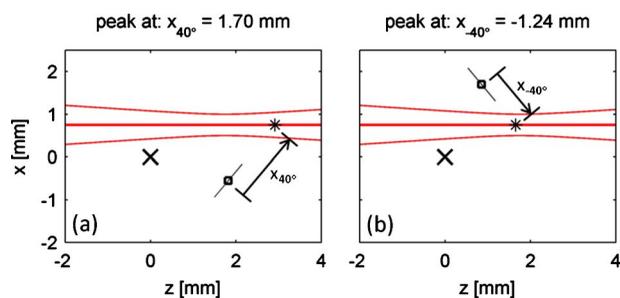


Fig. 4 Determined position along the internal x axis to maximize response of device at (a) $\theta=40$ deg and (b) $\theta=-40$ deg.

While still rotated to $\theta=-\theta_a$, the device is moved by the distance x_m , which is calculated using Eq. (1). The device is located at (z_d, x_d+x_m) , as shown in Fig. 5(a). The original device location is shown as a gray circle and the new location is marked by the black square.

The device is now moved along the internal z axis until its response is maximized. As shown in Fig. 3, this corresponds to the distance $-z_d$. The new device location, marked by a square, is $(0, x_d+x_m)$. Its previous position is indicated by a gray circle in Fig. 5(b).

3.2 Alignment Process for Internal x Axis

The device is intercepting the laser beam at two angular locations, $\theta = \pm \theta_a$. Now, the rotation of the device would move it in and out of the beam twice. At this point, the irradiance illuminating the device is still dependent on the angle of incidence and the measured radiation pattern is not accurate.

Figure 6 shows the laser beam intercepting the device at $\theta = \pm \theta_a$. The displacement of the device from the rotational axis is given by

$$x_d = x_m \left(\frac{\cos \theta_a}{1 - \cos \theta_a} \right). \tag{2}$$

The device is rotated back to $\theta=0$ deg, where it is moved along the internal x axis until its response is maximized. This distance is equal but opposite in direction to x_m , which was calculated during the internal z axis alignment process. This is illustrated in Fig. 7(a). After completing this measurement, the device is moved back to its previous location $(0, x_d+x_m)$.

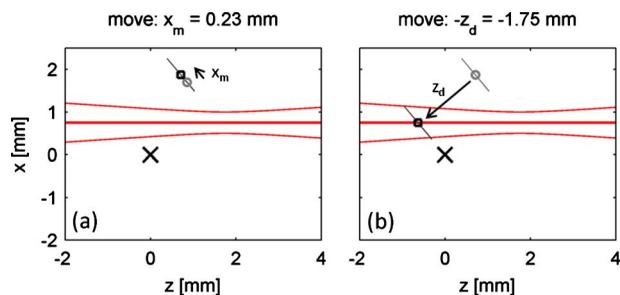


Fig. 5 Adjusting the (a) x and (b) z positions of the device.

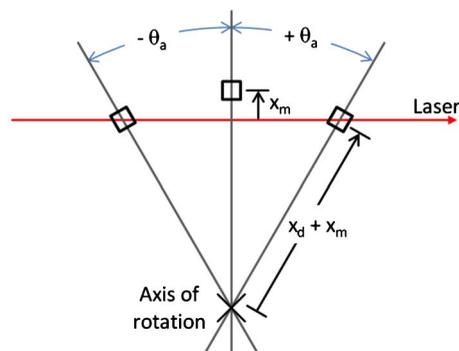


Fig. 6 Geometrical representation of device location with respect to the rotational axis for $\theta = \pm \theta_a$ and $\theta=0$ deg for alignment of the internal x position. The device is offset only in the x direction.

Using Eq. (2), x_d can be calculated and the device is moved by $-x_d-x_m$ along the internal x axis to its new position $(0,0)$. The device and the axis of rotation are coaligned as shown in Fig. 7(b).

3.3 Alignment Process for External Goniometer Position

When the device is rotated, its position in space will no longer shift, since the device and the axis of rotation are coaligned. The final part of the alignment process is to move the axis of rotation along with the device to the focus of the laser. The goniometer is moved along its external x axis, repositioning the axis of rotation and the device relative to the laser beam, until the device response is maximized. This corresponds to a distance of x_f , as shown in Fig. 8(a).

The device has not moved relative to the axis of rotation and is therefore still located at $(0,0)$. The location of the focus is shifted to $(z_f, 0)$. At this point, a radiation pattern can be measured. A small amount of defocus will not alter the shape of the radiation pattern. For example, displacing the device by ± 1.3 mm along the z axis from the focus, which is $230 \mu\text{m}$ in diameter, will still illuminate the device with 90% of the irradiance. This measured pattern is useful if only the shape of the radiation pattern is of interest. The magnitude of the response cannot be measured, since the actual irradiance on the device is not known.

The goniometer is moved along the external z axis until the device response is further maximized. This occurs when

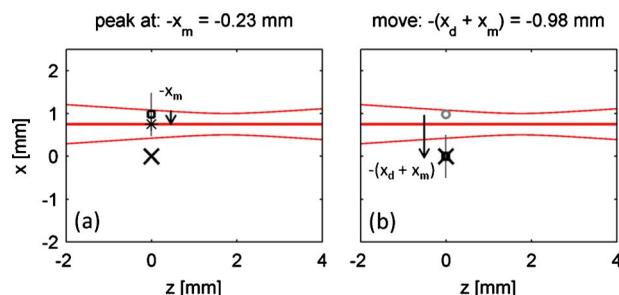


Fig. 7 (a) Determined position along the internal x axis to maximize response of device at $\theta=0$ deg and (b) adjusting the device location to coincide with the axis of rotation.

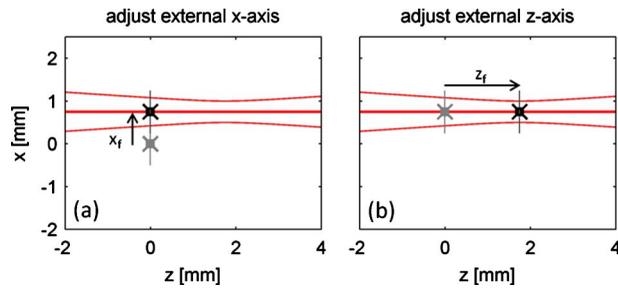


Fig. 8 External goniometer adjustment along the external (a) x axis and (b) y axis.

the device and focus are coaligned. Figure 8(b) shows that the device, axis of rotation, and focus are located at (0,0). If the device is rotated, it will remain in the focus of the laser, and a radiometrically accurate radiation pattern can be measured.

The alignment procedure assumes that the goniometer and device can be moved perfectly parallel and perpendicular with respect to each other and the laser beam. In a lab setup, such precision is difficult to achieve, and the goniometer will be slightly tilted with respect to the laser. Consequently, if the position of the goniometer or the device is adjusted along the x or z direction, a small shift in the z or x direction will be introduced. After completing this alignment procedure, the axis of rotation, the device, and the laser beam will be nearly, but not quite coaligned. Repeating the procedure will minimize this error.

When the device is mounted in the goniometer, a small amount of tilt could be introduced, causing the substrate surface on which the device is fabricated to not be parallel to the internal goniometer x axis. This misalignment has no impact on the alignment procedure and the device will be coaligned with the axis of rotation and the focus of the laser beam. However, the measured pattern will be tilted. This problem is solved by coaligning a visible HeNe laser with the CO₂ laser. By observing back reflections, it is possible to ensure that the substrate surface is perpendicular to the laser beam and therefore parallel to the internal goniometer x axis.

The CO₂ laser power exhibits small fluctuations with time. During this alignment procedure, the device response is observed. The laser power fluctuations may cause the device to indicate a maximum response when it is not positioned at the center of the laser beam. In this case, a reference power meter should be used to monitor the power fluctuations. If the responsivity of the device is linear, the measured response can be divided by the reference power. This normalized response can be used throughout the alignment procedure.

4 Conclusion

Measuring the receiving radiation pattern of an antenna-coupled detector is one method to characterize the directional properties of the device. The detector must be aligned precisely, since at IR frequencies, the involved dimensions are small. A procedure was outlined, describing how to align an antenna-coupled detector to the rotational axis of a goniometer and the focus of a laser beam. The device was rotated to various angles, where the distance

from the device to the laser beam was determined by maximizing the response. Using this information, we can calculate how to move the device to coalign it with the axis of rotation and the focus of the laser beam. This procedure was used to measure radiation patterns in Ref. 9, where good agreement with theoretical predictions is shown.

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